



S/N 09/471,460

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Thomas A. Figura et al.

Examiner: Calvin Lee

Serial No.: 09/471,460

Group Art Unit: 2818

Filed: December 22, 1999

Docket No.: 303.932US4

Title: USE OF A PLASMA SOURCE TO FORM A LAYER DURING THE
FORMATION OF A SEMICONDUCTOR DEVICE

AMENDMENT AND RESPONSE UNDER 37 CFR § 1.111

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

This paper responds to the Office Action mailed on February 7, 2006. Please amend the above-identified patent application as follows.

This response is accompanied by a Petition, as well as the appropriate fee, to obtain a two-month extension of the period for responding to the Office Action, thereby moving the deadline for response from May 7, 2006 to July 7, 2006.